

Special Issue

Advances of Chemical Preparation Methods of Nanomaterials

Message from the Guest Editor

This Special Issue of the MDPI *Processes* journal on the topic of “Advances of Chemical Preparation Methods of Nanomaterials” provides the opportunity to contribute with high-quality works focused on the development of novel processes to obtain nanostructured materials. The topics covered are as follows, but works in related fields are welcome:

- Preparation of nanostructured inorganic particles;
- Synthesis of nanoporous materials;
- Crystal growth of nanostructured films;
- Particle size and shape dependence of physical and chemical properties.

Guest Editor

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Message from the Editor-in-Chief

You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

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